Notice of Allowability	Application No.	Applicant(s)
	10/697,833	CHENG ET AL.
	Examiner	Art Unit
	Trung Dang	2823
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication IGHTS. This application is subject to	olication. If not included will be mailed in due course. THIS
1. X This communication is responsive to the amendment filed	<u>12/28/05</u> .	
2. The allowed claim(s) is/are <u>1-32</u> .		
3.		
Attachment(s)  1. Notice of References Cited (PTO-892)  2. Notice of Draftperson's Patent Drawing Review (PTO-948)  3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Summary Paper No./Mail Da 08), 7. ☐ Examiner's Amenda	te

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## Allowable Subject Matter

1. The following is an examiner's statement of reasons for allowance:

Prior art of record does not teach or suggest the claimed limitation "performing a plasma treatment directly on the patterned and etched layer of gate material and directly on exposed surfaces of the provided substrate, wherein a gas based layer is formed over the patterned and etched layer of gate material and the exposed surfaces of the provided substrate after performing the plasma treatment".

Reference to Gardner et al. (US 6,323,519) involves the formation of oxide layer 22 before a plasma treatment. It would have been unobvious to exclude the oxide layer 22 from the plasma treatment because doing so would destroy the intended purpose of the reference. As for Saul et al. reference (US 5,425,843), there is no evidence indicating that the plasma treatment with H2 and N2 would result in a gas based layer formed after the plasma treatment.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

2. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trung Dang whose telephone number is 571-272-1857. The examiner can normally be reached on Mon-Friday 9:30am-6:00pm.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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